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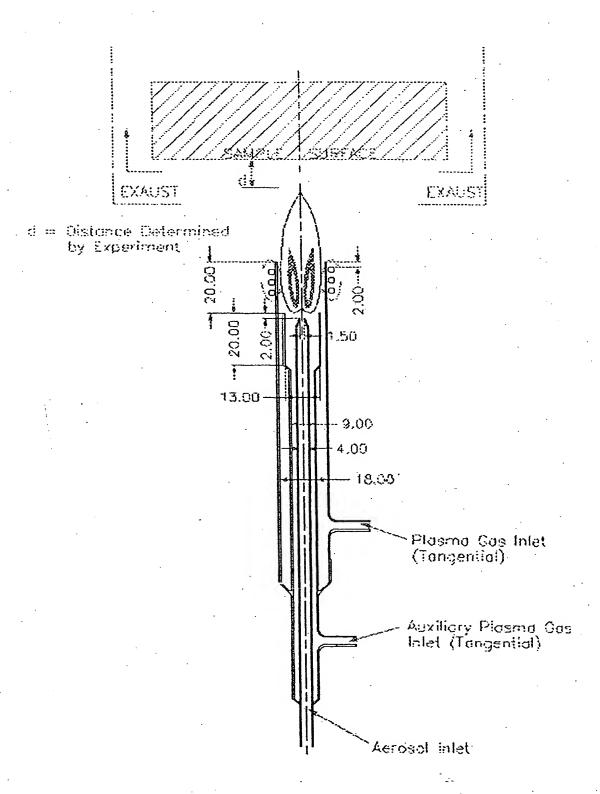
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Fig 1: ICP Torch



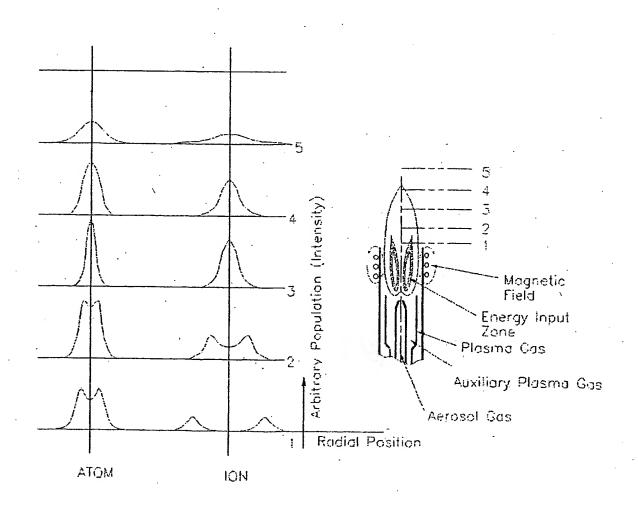
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Fig. 2: Atom and Ion Distribution in the ICP



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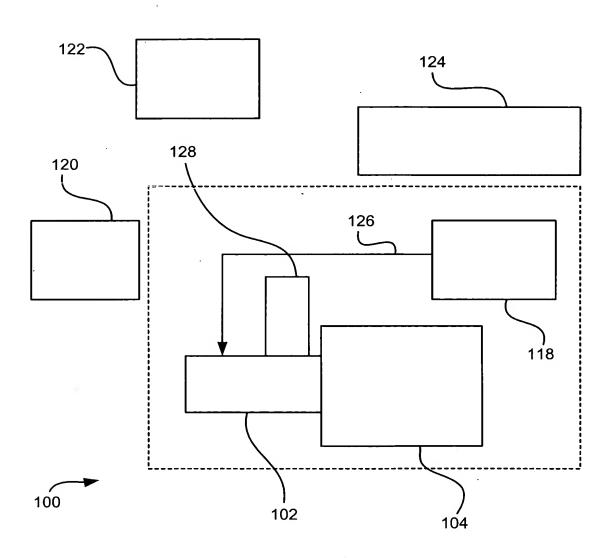
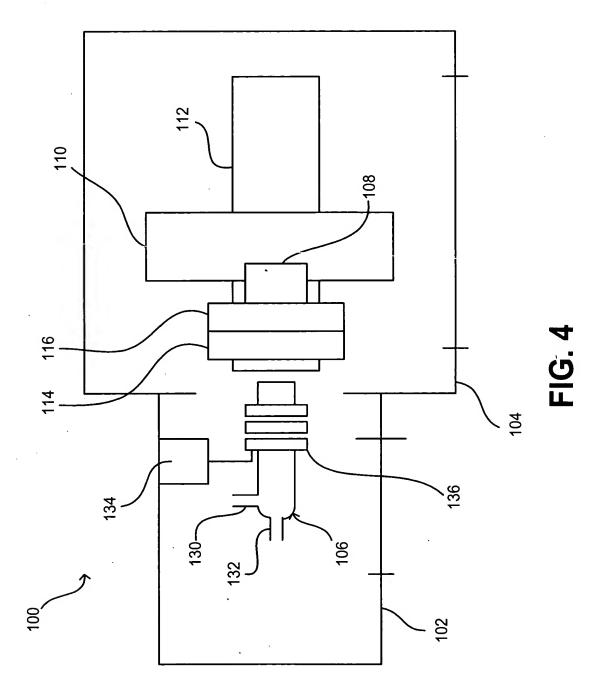


FIG. 3

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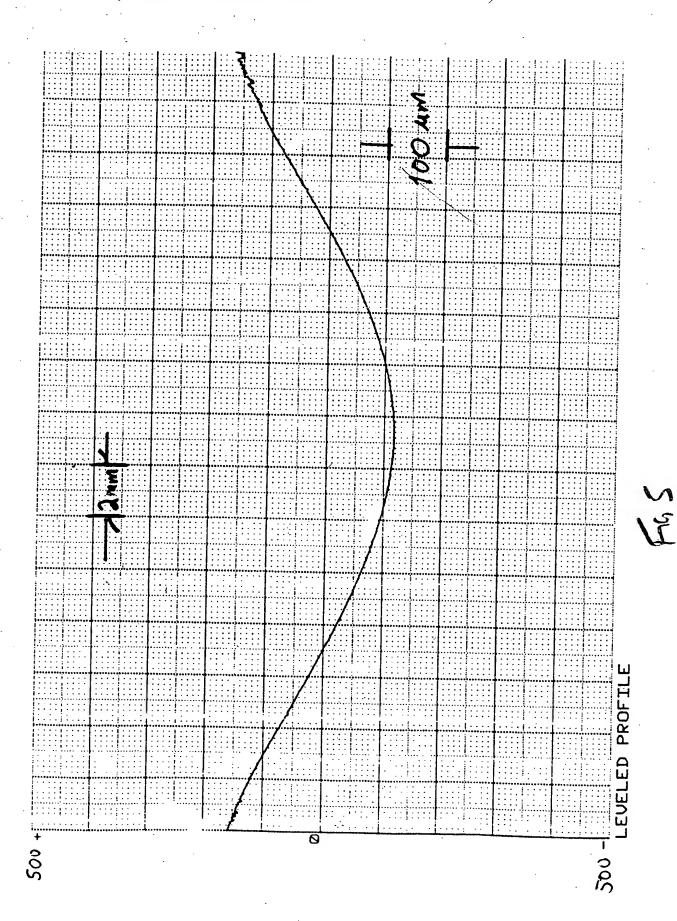


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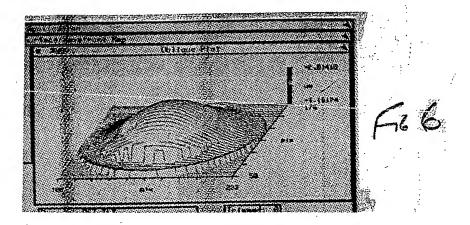
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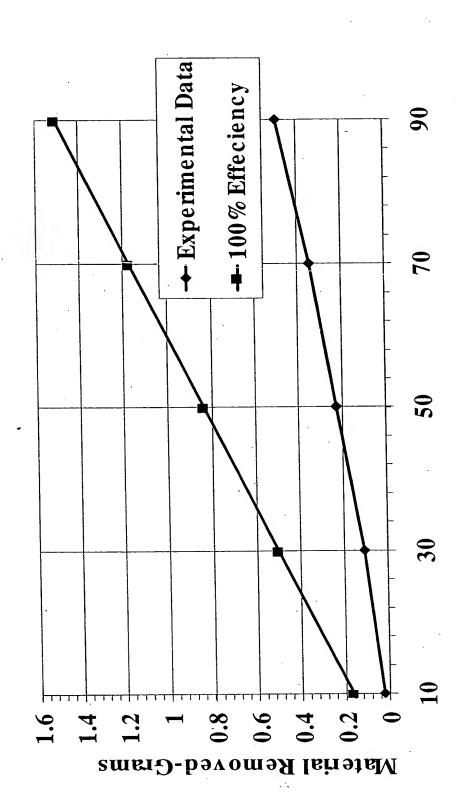
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Effect of Reaction Gas Flow Rate on Removal



Reaction Gas Concentration

Effect of Distance from Plasma

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Distance (mm) 00 25 0.18 0.14 0.12 0.12 0.08 0.02 90.0 0.04 Grams Removed

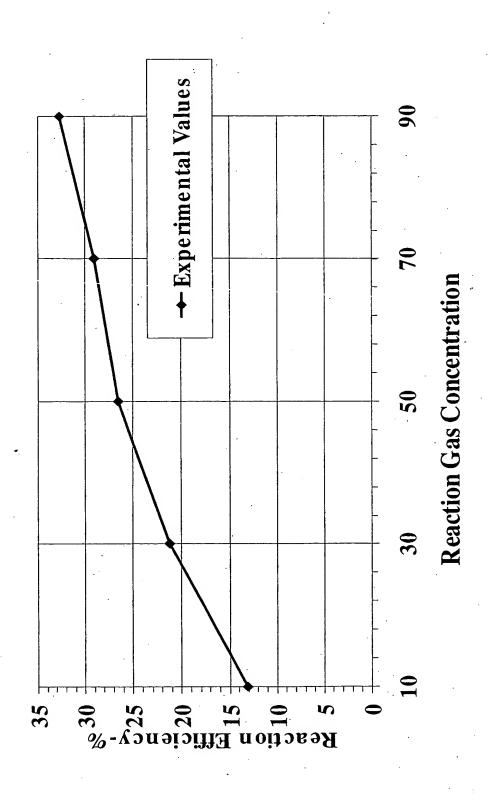
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Effect of Reaction Gas Flow Rate on Efficiency



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